

Special Issue

Environmental Pollutant: Analysis, Monitoring and Emerging Processes for Abatement

Message from the Guest Editors

Emerging contaminants (PFAS, pharmaceuticals, flame retardants, etc.) are widely distributed in the environment due to being directly discharged from anthropogenic sources and/or their slow degradation in wastewater treatment plants. This Special Issue welcomes scientific articles focused on the use of physical and chemical processes able to remove pollutants from water, soil and air, as well as their analysis using innovative analytical methodologies and their continuous monitoring.

Guest Editors

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Deadline for manuscript submissions

closed (20 November 2024)



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About the Journal

Message from the Editor-in-Chief

As the world of science becomes ever more specialized, researchers may lose themselves in the deep forest of the ever increasing number of subfields being created. This open access journal Applied Sciences has been started to link these subfields, so researchers can cut through the forest and see the surrounding, or quite distant fields and subfields to help develop his/her own research even further with the aid of this multi-dimensional network.

Editor-in-Chief

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